

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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Applicant	:	Sprey, et al.	Group Art Unit	Unknown
Appl. No.	:	<u>09/ 771673</u>		
		<u>Unknown</u>		
Filed	:	Herewith		
For	:	METHOD AND		
		INSTALLATION FOR		
		ETCHING A SUBSTRATE		
Examiner	:	<u>Unknown</u>		

PRELIMINARY AMENDMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

Dear Sir:

Prior to examination of the above-captioned application, please amend the application as follows:

IN THE SPECIFICATION:

Please amend the specification as follows:

On page 1, immediately before line 3, please insert--Field of the Invention--.

On page 1, line 3, please replace "according to the preamble of claim 1" with --and installation for etching a substrate.--

On page 1, between lines 3 and 4, please insert --Background of the Invention--.

On page 1, between lines 31 and 32, please insert --Summary of the Invention--.

On page 2, lines 3-4, please replace the sentence with --One aspect of the present

introduced into the etching chamber via an auxiliary chamber positioned within a first path. The